IMPROVED EVALUATION OF PID CELL TESTS

Consideration of variable HV stress levels

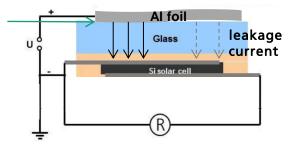


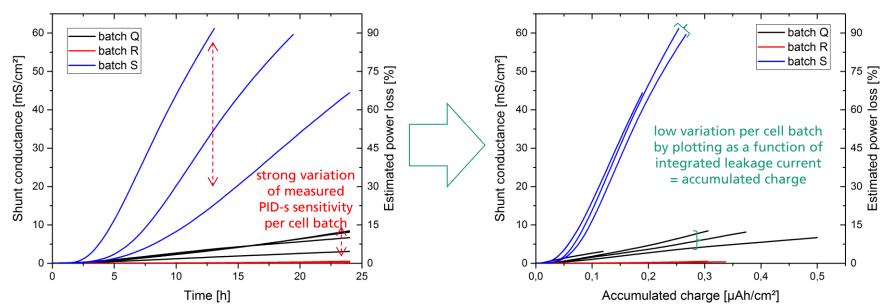
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Improved evaluation for PID tests on cell and mini module level

- PID test on cell level is inexpensive method for monitoring/quality checks of sensitivity to PID-s*
- Sometimes the top electrode (Al foil, metal plate) hasn't tight contact to the glass surface
- This leads to uncontrolled/reduced high voltage (HV) stress by reduced leakage currents
- → Apparent variation of PID-s* susceptibility within one cell batch at constant conditions (1)
- → Can be eliminated by plot as a function of accumulated charge (2) instead of time





(1) common evaluation: plot of degradation indicator as a function of time

(2) new evaluation: plot of degradation indicator as a function of accumulated charge

PID cell test conditions:

PIDcon by Freiberg Instruments

Temperature: 85 °C

Voltage: 1000 V (neg. on cell, pos. on glass)

Stressed area: 10x10 cm²

EVA: Avaluxe EVA

Glass: float glass/white glass 3.2 mm

